Docket No. 740756-2183



2814 JACO. 11.C

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Shunpei YAMAZAKI

Serial No. 09/620,968

DExaminer: Nathan W. Ha
Filed: July 20, 2000

Group Art Unit: 2814

For: METHOD OF FORMING INSULATION FILMS,

CAPACITANCES, AND SEMICONDUCTOR DEVICES

CAPACITANCES

Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage for First Class Mail in an envelope addressed to: Commissioner for Patents, P. O. Box 1450, Alexandria, VA 22312/1450, on October 1.7, 2003.

REQUEST FOR ACKNOWLEDGMENT OF INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents Alexandria, VA 22313-1450

Sir:

An Information Disclosure Statement with Form PTO-1449 was filed in the above-identified patent application on July 20, 2000. Applicants have not yet received back from the Examiner a copy of the Form PTO-1449 initialed to acknowledge the fact that the Examiner has considered the cited disclosed information.

The Examiner is requested to initial and return to the undersigned a copy of the subject Form PTO-1449.

Should there be any questions concerning this communication, please telephone the undersigned at the number set forth below.

Respectfully submitted,

Jerome W. Massie IV Registration No. 48,118

Nixon Peabody LLP 401 9th Street, N.W. Suite 900

Washington, DC 20004-2128

(202) 585-8000 (202) 585-8080 FAX

Form PTO-1 (Rev. 8-83)	449	U.S. Department of Patent and Trade		Attorney Docket No. 0756-21	183	Serial No. Not	Yet Assi	gned
INFOR	EAW!	TION DISCLOSURE STATE	MENT	Applicant: Shunpei YAMAZA	AKI			
OCT 202	2 co	(Use several sheets if necessary)		Filing Date: July 20, 2000		Group: 2811		
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INFORMATION DISCLOSURE STATEMENT				Applicant: Shunp i YAMAZAKI					
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U.S. Department of Commerce Patent and Trademark Office Attorney Docket No. 0756-2183

Applicant: Shunpei YAMAZAKI

Serial N . Not Yet Assigned

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Attorney Docket No. 0756-2183 Form PTO-1449 U.S. Department of Commerce Serial No. Not Yet Assigned (Rev. 8-83) Patent and Trademark Office Applicant: Shunpei YAMAZAKI INFORMATION DISCLOSURE STATEMENT 2 0 2003 Group: 2811 Filing Date: July 20, 2000 (Use several sheets if necessary) **U.S. PATENT DOCUMENTS Document Number** Date Name Class Subclass Filing Date (if Examiner Initial appropriate) 5,047,359 09/10/91 Nagatomo 10/10/91 **Pfiester** 5,047,812 10/01/91 Kojima 5,053,842 10/08/91 5,056,010 Huang 02/04/92 Kimura 5,086,010 2/23/93 Suguro 5,189,503 08/04/92 McDavid et al. 5,136,534 **FOREIGN PATENT DOCUMENTS** Date Country Class Subclass Translation_ **Document Number** Yes No Full 08/19/81 **United Kingdom** 2 103 879A Full WO 89/02655 03/23/89 PCT **Abstract** JP 01-171275 7/6/89 Japan Abstract 1/31/87 JP 62-23117 Japan Abstract JP 62-298119 12/25/87 Japan Abstract 2/16/90 Japan JP 02-47256 **Abstract** 24/1/91 Japan JP 03-16129 Abstract 4/4/91 JP 03-79028 Japan Full EP 445535 11/9/91 European Full 03/01/90 European EP 349187 Х 8/16/89 1-203666 Japan X 11/21/87 62-269363 Japan X 8/17/88 63-199456 Japan Χ 10/4/89 Japan 1-248557 Χ 3/20/90 Japan 2-79475 **Date Considered** Examiner *EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Translation

Yes No Abstract

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Serial No. Not Yet Attorney Docket No. 0756-2183 U.S. Department of Commerce Form PTO-1449 Assigned Patent and Trademark Office (Rey_8-83) INFORMATION DISCLOSURE STATEMENT Applicant: Shunpei YAMAZAKI 2 0 2003 (Use several sheets if necessary) Group: 2811 Filing Date: July 20, 2000 TRADEMARY OF FOREIGN PATENT DOCUMENTS **Subclass** Class Country Date **Document Number** 6/8/84 Japan JP 59-99726 03/28/89 Japan JP 64-82557 09/08/89 Japan JP 01-225148

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